

L Number	Hits	Search Text	DB	Time stamp
1	706468	resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))	USPAT; US-PGPUB; EPO; JPO; DERWENT USPAT	2003/12/18 15:50
2	0	((peb! post-exposure adj bake) with harden\$3 with (implant\$3)		2003/12/18 15:56
3	0	((peb! post-exposure adj bake) with harden\$3 with (implant\$3)	USPAT; US-PGPUB	2003/12/18 15:56
5	0	((peb! post-exposure adj bake) with (resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) with (implant\$3)	USPAT; US-PGPUB	2003/12/18 15:56
6	17	((peb! post-exposure adj bake) with (resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) with (ion)	USPAT; US-PGPUB	2003/12/18 15:58
7	701	((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) with (ion near3 implant\$3) with energy with (dosage dose kev)	USPAT; US-PGPUB	2003/12/18 16:01
8	2	("5886119").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 16:00
9	0	((("5886119").PN.) and negative	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 16:00
10	2	((("5886119").PN.) and positive	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 16:00
11	1	((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) with (ion near3 implant\$3) with energy with (dosage dose kev) with harden\$3	USPAT; US-PGPUB	2003/12/18 16:02
12	18686	((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) near2 negative	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 16:03
17	6	((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) near2 negative) with ((peb! post-exposure adj bak\$3) with (known conventional\$2 typical\$2)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 16:11
18	1	((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) near2 negative) with (ion implant\$6) with (dose dosage) with (energy ev!) with (known conventional\$2 typical\$2)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 16:18
20	18296	off-axis off adj axis	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 16:18
21	1	((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) with (ion implant\$6) with (dose dosage) with (energy ev!) with (known conventional\$2 typical\$2)) and (off-axis off adj axis)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 16:19

19	49	(resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) with (ion implant\$6) with (dose dosage) with (energy ev!) with (known conventional\$2 typical\$2)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 16:44
22	4	(resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) with (ion implant\$6) with (dose dosage) with (energy ev!) with (known conventional\$2 typical\$2) with harden\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 16:27
23	44	(resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) with (ion implant\$6) with (known conventional\$2 typical\$2) with harden\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 16:39
25	0	us-6200903-\$\$.did. and (kev energy)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 16:38
26	1	us-6121158-\$\$.did. and (kev energy)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 16:39
27	4072	((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) with (ion implant\$6)) same (kev)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 16:40
28	2076	((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) with (ion implant\$6)) with (kev)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 16:40
29	11	((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) with (ion implant\$6)) with (kev) with harden\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 16:40
30	14	(resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) with (off-axis off adj axis) with (known conventional\$2 typical\$2)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 16:52
-	118	CHANG-CHING-YU-.in. CHANG-C-Y-.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 13:18
-	706468	resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 15:50
-	25342	(resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) near2 first!	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 13:19
-	20762	(resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) near2 second!	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 13:19
-	61643	first! near2 (expos\$3 irradiat\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 13:20
-	51203	second! near2 (expos\$3 irradiat\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 13:20
-	643426	vertical\$2 with horizontal\$2	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 13:20

-	1408961	orthogonal\$2 perpendicular\$2 (right adj angle) ("90" adj degree)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 13:21
-	203	430/312.ccls. and 430/394.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 13:24
-	5	(CHANG-CHING-YU-.in. CHANG-C-Y-.in.) and ((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) near2 first!) and ((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) near2 second!) and (first! near2 (expos\$3 irradiat\$4)) and (second! near2 (expos\$3 irradiat\$4))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 13:29
-	903	((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) near2 first!) same ((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) near2 second!) same (first! near2 (expos\$3 irradiat\$4)) same (second! near2 (expos\$3 irradiat\$4))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 13:30
-	30	((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) near2 first!) same ((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) near2 second!) same (first! near2 (expos\$3 irradiat\$4)) same (second! near2 (expos\$3 irradiat\$4)) same ((vertical\$2 with horizontal\$2) (orthogonal\$2 perpendicular\$2 (right adj angle) ("90" adj degree)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 13:38
-	83	(430/312.ccls. and 430/394.ccls.) and ((vertical\$2 with horizontal\$2) (orthogonal\$2 perpendicular\$2 (right adj angle) ("90" adj degree)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 13:39
-	80	((430/312.ccls. and 430/394.ccls.) and ((vertical\$2 with horizontal\$2) (orthogonal\$2 perpendicular\$2 (right adj angle) ("90" adj degree)))) not ((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) near2 first!) same ((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) near2 second!) same (first! near2 (expos\$3 irradiat\$4)) same (second! near2 (expos\$3 irradiat\$4)) same ((vertical\$2 with horizontal\$2) (orthogonal\$2 perpendicular\$2 (right adj angle) ("90" adj degree)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 14:26
-	17	((("4732830") or ("5077157") or ("6303272") or ("20020106587") or ("5959325") or ("6184151") or ("6571384") or ("20020059557") or ("20020172901")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 14:27
-	18296	off-axis off adj axis	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 14:28
-	11665	"248" adj (nm nanometer nano-meter nano adj meter) krf	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 14:28

-	1244500	positive negative	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 14:29
-	0	((("4732830") or ("5077157") or ("6303272") or ("20020106587") or ("5959325") or ("6184151") or ("6571384") or ("20020059557") or ("20020172901")).PN.) and (off-axis off adj axis) and (off-axis off adj axis) and (positive negative) and ("248" adj (nm nanometer nano-meter nano adj meter) krf)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 14:30
-	7	((("4732830") or ("5077157") or ("6303272") or ("20020106587") or ("5959325") or ("6184151") or ("6571384") or ("20020059557") or ("20020172901")).PN.) and ((off-axis off adj axis) ("248" adj (nm nanometer nano-meter nano adj meter) krf) (positive negative))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 14:44
-	1	("6664028").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/18 15:50